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| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO | ONFIRMATION NO. |
|----------------------|---------------|----------------------|-------------------------|-----------------|
| 09/884,670 | 06/19/2001 | Stephen R. Fox | YOR920010104(14270) | 4482 |
| 75 | 90 10/22/2002 | | | |
| Steven Fischman Esq. | | | EXAMINER | |
| 400 Garden City | | | POMPEY, RON EVERETT | |
| Garde City, NY | 11530 | | ART UNIT | PAPER NUMBER |
| | | | 2812 | |
| | | | DATE MAILED: 10/22/2002 | |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | Application No. | (Applicant/s) | | |
|---|--|--|--|--|
| | | Applicant(s) | | |
| Office Action Summary | 09/884,670 | FOX ET AL. | | |
| omec Action Summary | Examiner | Art Unit | | |
| The MAILING DATE of this commi | Ron E Pompey | 2812 | | |
| Period for Reply | unication appears on the cover sheet wit | n the correspondence address | | |
| A SHORTENED STATUTORY PERIOD THE MAILING DATE OF THIS COMMUI - Extensions of time may be available under the provisio after SIX (6) MONTHS from the mailing date of this cor - If the period for reply specified above is less than thirty - If NO period for reply is specified above, the maximum - Failure to reply within the set or extended period for reply received by the Office later than three months earned patent term adjustment. See 37 CFR 1.704(b). Status | NICATION. ons of 37 CFR 1.136(a). In no event, however, may a regenmunication. (30) days, a reply within the statutory minimum of thirty statutory period will apply and will expire SIX (6) MONT ply will, by statute, cause the application to become ABAs after the mailing date of this communication, even if tire. | ply be timely filed (30) days will be considered timely. HS from the mailing date of this communication. | | |
| 1) Responsive to communication(s) | filed on <u>09 August 2002</u> . | | | |
| 2a)⊠ This action is FINAL . | 2b) ☐ This action is non-final. | | | |
| 3) Since this application is in condition closed in accordance with the pra | on for allowance except for formal matt actice under <i>Ex parte Quayle</i> , 1935 C.D | ers, prosecution as to the merits is 11, 453 O.G. 213. | | |
| 4)⊠ Claim(s) <u>1-22,25-36,40,48 and 49</u> | is/are pending in the application. | • | | |
| 4a) Of the above claim(s) is/ | • | | | |
| 5)☐ Claim(s) is/are allowed. | | | | |
| 6) Claim(s) <u>1-22,25-36,40,48 and 49</u> | is/are rejected. | | | |
| 7) Claim(s) is/are objected to. | • | | | |
| 8) Claim(s) are subject to restr | iction and/or election requirement. | | | |
| Application Papers | • | | | |
| 9)☐ The specification is objected to by the | he Examiner. | | | |
| 10) The drawing(s) filed on is/are | e: a) accepted or b) objected to by the | e Examiner. | | |
| | bjection to the drawing(s) be held in abeyan | | | |
| 11) The proposed drawing correction file | ed on is: a)□ approved b)□ dis | sapproved by the Examiner. | | |
| If approved, corrected drawings are re | equired in reply to this Office action. | | | |
| 12)☐ The oath or declaration is objected t | to by the Examiner. | | | |
| Priority under 35 U.S.C. §§ 119 and 120 | | | | |
| 13) Acknowledgment is made of a clair | m for foreign priority under 35 U.S.C. § | 119(a)-(d) or (f). | | |
| a) ☐ All b) ☐ Some * c) ☐ None of: | | | | |
| Certified copies of the priority | y documents have been received. | | | |
| 2. Certified copies of the priority | y documents have been received in App | plication No | | |
| application from the Inter | s of the priority documents have been remained. Some seen remained to the priority documents have been remained to the certified copies not remained to the certified copies not remained to the certified copies not remained. | • | | |
| 14) Acknowledgment is made of a claim | • | | | |
| | inguage provisional application has bee | en received. | | |
| Attachment(s) | | | | |
| Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (I) Information Disclosure Statement(s) (PTO-1449) F | PTO-948) 5) Notice of Info | mmary (PTO-413) Paper No(s) ormal Patent Application (PTO-152) | | |
| S. Patent and Trademark Office PTO-326 (Rev. 04-01) | Office Action Summary | Part of Paper No. 9 | | |

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DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-22, 25-36, 40, 48-49 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sadana et al. (US 6,090,689) in further view of Tachimori et al. (US 5,534,446) and Sadana et al. (US 5,930,643).

Sadana ('689) discloses the steps of:

For claims 1-22 and 25-29:

implanting oxygen ions (14, 18, fig. 2) into a surface of a Si-containing substrate, said implanted oxygen ions having a concentration sufficient to form a buried oxide region during a subsequent annealing step; and

annealing said substrate wherein, said implanted oxygen ions form said buried oxide region (22, fig. 3) (col. 3, lns. 6-12 and col. 4, ln. 8 – col. 5, ln. 34).

Sadana ('689) discloses the claimed invention except for:

wherein the annealing step is carried out in an ambient gas comprising at least one high-surface mobility gas that hinders oxide growth; and

wherein the annealing step comprises the steps of: partially annealing the substrate so as to form a surface layer of oxygen on the substrate; stripping the surface layer of oxygen; and continuing the annealing to complete the formation of said BOX

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region. However, Tachimori teaches an annealing step is carried out in an ambient gas comprising at least one high-surface mobility gas that hinders oxide growth (col. 7, In. 55 – col.8, In.5) and Sadana('643) teaches partially annealing the substrate so as to form a surface layer of oxygen on the substrate; stripping the surface layer of oxygen; and continuing the annealing to complete the formation of said BOX region (col. 5, Ins. 22-43).

Therefore it would have been obvious to those of ordinary skill in the art to combine Tachimori and Sadana ('643) because, the high-surface mobility gas will prevent the semiconductor surface from roughening and that the oxide is of poor quality and needs to be removed before forming a device on the SOI substrate.

Response to Arguments

3. Applicant's arguments filed 6-18-02, pertaining to claims 1-22, 25-36, 40, 48-49, have been fully considered but they are not persuasive. The applicant argues that neither of the prior art stated in the rejection disclose the annealing step performed in an ambient gas comprises from 0 –90% oxygen and from about 10-100% of N₂. The examiner would like to point out that with the range that is claimed by the applicant that an annealing disclosed as in 100% N₂ would read on the claimed invention (which is disclosed in the background of the invention section of the specification of the present invention). Sadana does in column 4 state that a "post implantation anneal was done in an inert ambient nominally mixed with less than 2 percent oxygen". therefore it would be inherent that if the annealing is done within the specified range disclosed by applicant than applicant's desired results would be obtained.

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Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time 4.

policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE

MONTHS from the mailing date of this action. In the event a first reply is filed within

TWO MONTHS of the mailing date of this final action and the advisory action is not

mailed until after the end of the THREE-MONTH shortened statutory period, then the

shortened statutory period will expire on the date the advisory action is mailed, and any

extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

the advisory action. In no event, however, will the statutory period for reply expire later

than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Ron E Pompey whose telephone number is (703) 305-

3016.

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October 21, 2002

Supervisory Patent Examiner

Technology Center 2800